

Erratum: On the Nature of “Easy Paths” for the Diffusion of Oxygen in Thermal Oxide Films on Aluminum*

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Several minor errors were made on this paper. The corrections are as follows:

Page 430, Line 1, $(100)_{\text{ox}} // (100)_{\text{Al}} \rightarrow (110)_{\text{ox}} // (110)_{\text{Al}}$.

Page 430, Line 18, $1.0 \times 10^{-10} \rightarrow 1.0 \times 10^{10}$.

Page 431, Line 3, $(100) \rightarrow (110)$.

Page 432, Line 5, $(100) \rightarrow (110)$.

Page 435, Line 18, 19% \rightarrow 59% (assuming the density of Al and $\gamma\text{-Al}_2\text{O}_3$ to be 2.7 and 3.2g/cm³ Pilling Bedworth ratio is 1.59).

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